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PATENT TRADEMARK OFFICE

Patent *amr*
Case No.: 57181US002**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

First Named Inventor: BAUDE, PAUL F.
 Application No.: 10/076003 Group Art Unit: 2814
 Filed: February 14, 2002 Examiner: H. Trinh
 Title: APERTURE MASKS FOR CIRCUIT FABRICATION

AMENDMENT AND RESPONSE

Commissioner for Patents
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<i>June 27, 2003</i> Date	<i>Hylis H. Froelke</i> Signed by: Hylis H. Froelke

Dear Sir:

This is in response to the Office Action mailed on March 28, 2003. Reconsideration of the application is requested in view of the following remarks.

In the Claims**FAX RECEIVED**

Please amend claim 20 to read as follows:

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20. (amended) An integrated circuit comprising:
 a deposition substrate;
 a patterned first electrode layer formed adjacent the deposition substrate;
 a patterned organic semiconductor layer formed adjacent the first electrode layer;

and

a second patterned electrode layer deposited adjacent the organic semiconductor layer, wherein the patterned first electrode layer, the patterned organic semiconductor layer, and the second patterned electrode layer are each defined by a repositionable aperture mask.

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Please add new claims 39 and 40:

10/076003

**Office of Intellectual Property Counsel
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Date: June 27, 2003**Number of pages including cover sheet: 6**

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Remarks: ☐ Urgent ☐ Acknowledge ☐ Reply ASAP ☐ Please Comment

AMENDMENT AND RESPONSE

Title: "APERTURE MASKS FOR CIRCUIT FABRICATION"

Application Number: 10/076003

Filing Date: February 14, 2002

First Named Inventor: Baude, Paul F.

Attorney Case Number: 57181US002

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